

# Wafer scale fabrication of graphene microelectrode arrays for the detection of DNA hybridization

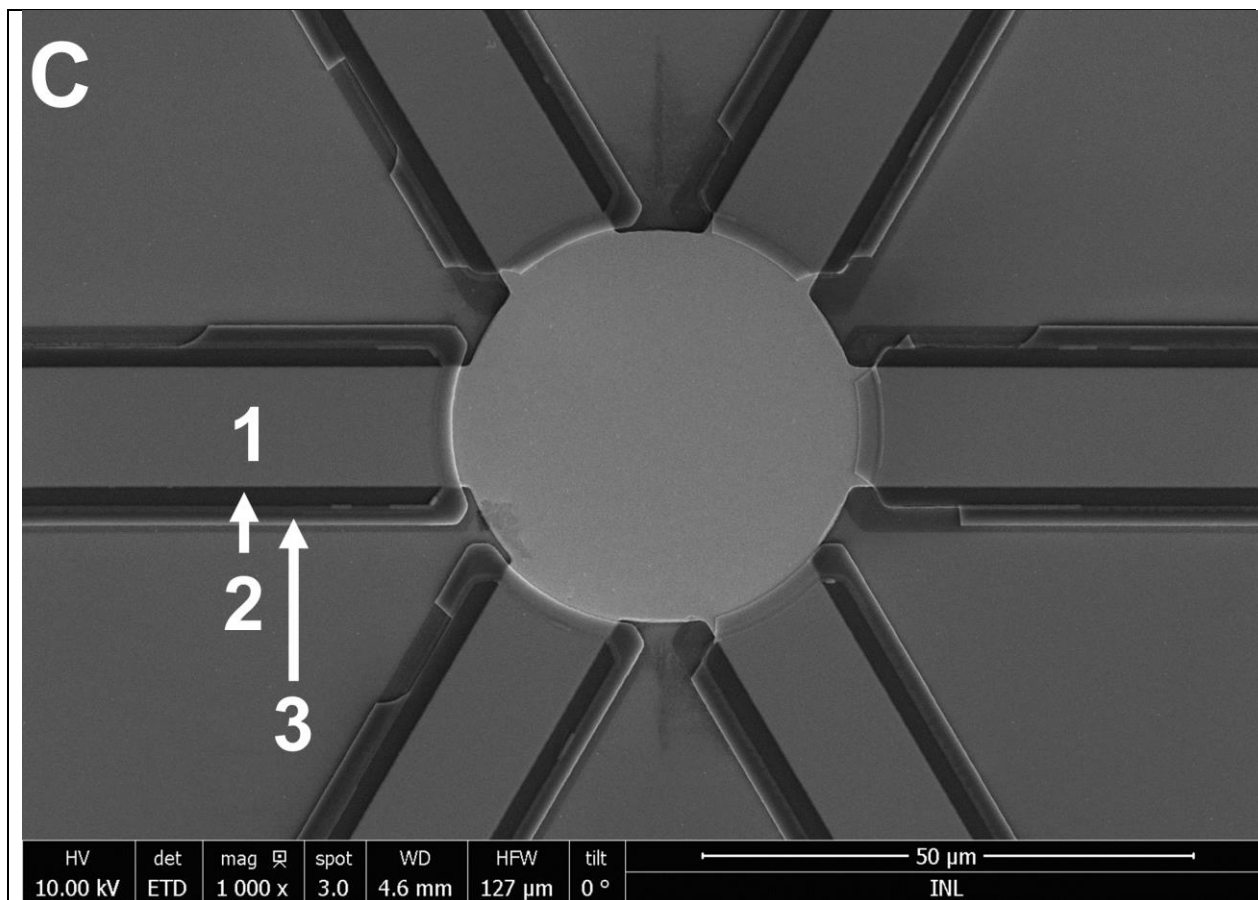
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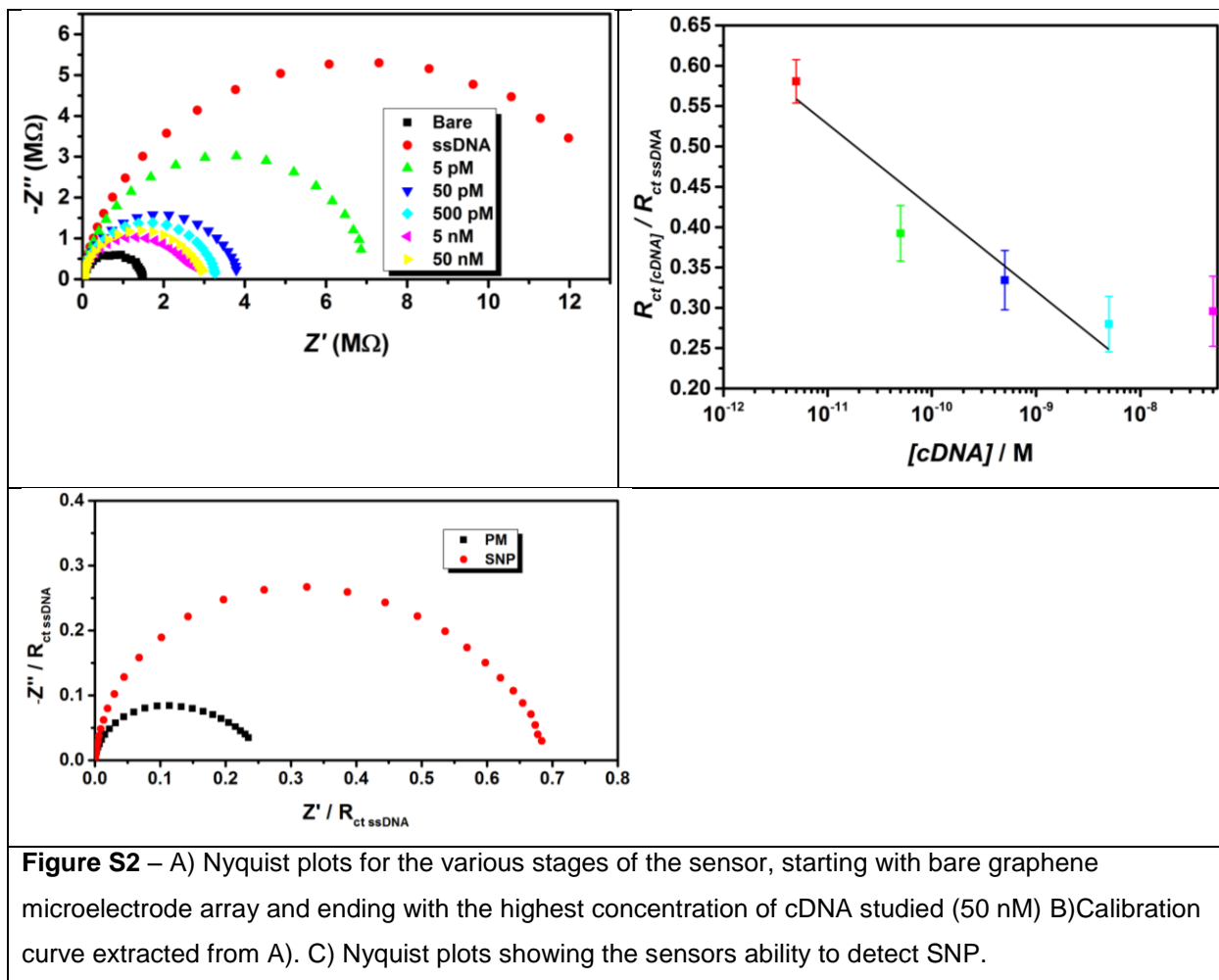
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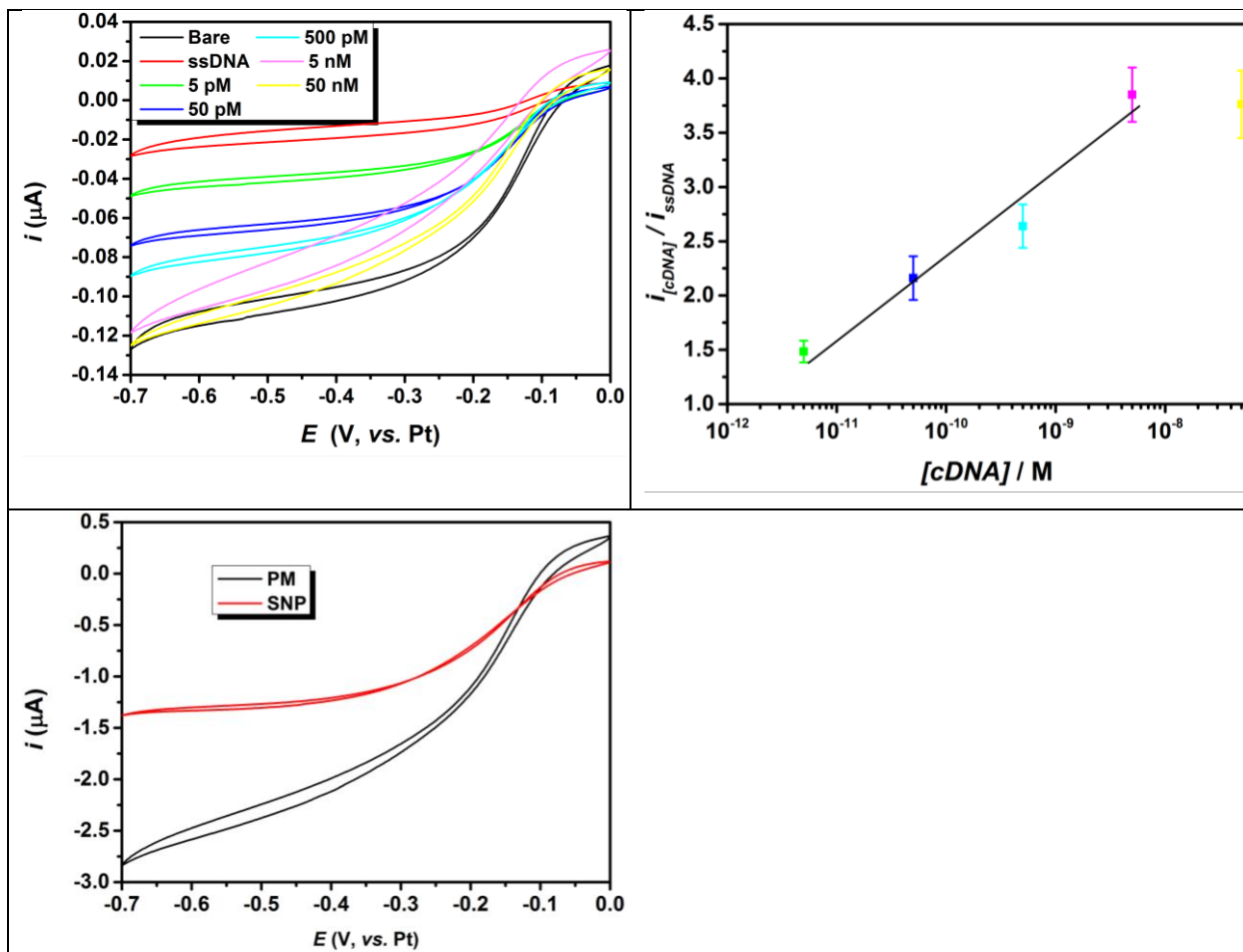
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## Electronic Supplementary Information



**Figure S1** – Figure 1C from the main text in full size, so that the features 1, 2 and 3 are easily seen. SEM image of a single microelectrode. Six lines connect the electrode to its neighbors. The gold lines are covered with a stack of silicon nitride and oxide, noted 1). The sides of the passivated gold layer, which is composed of passivation stack on the oxidized silicon, is noted 2). The outer passivation, which is suspended due to the removal of the stooping layer underneath, is noted 3)





**Figure S3** – A) Cyclic voltammograms for the various stages of the sensor, starting with bare graphene microelectrode array and ending with the highest concentration of cDNA studied (50 nM). B) Calibration curve extracted from A). C) Cyclic voltammograms showing the sensors ability to detect SNP.